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Large-area growth of SnS₂ nanosheets by chemical vapor deposition for high-performance photodetectors

Two-dimensional tin disulfide (SnS_2) is very popular in electronic, optoelectronic, energy storage, and conversion applications. However, the uncontrollable large-area growth of SnS_2 nanosheets and unsatisfactory performance of the photodetectors based on SnS_2 have hindered its applications. Here, we propose a chemical vapor deposition (CVD) method using $SnCl_2$ as a precursor to grow SnS_2 nanosheets. We found that the as-grown SnS_2 nanosheets were high-quality crystal structures. Then,

photodetectors based on the as-grown SnS₂ were fabricated and, exhibited a high responsivity (1400 A

 W^{-1}), fast response rate (a response time of 7 ms and a recovery time of 6 ms), perfect external quantum

efficiency (EQE) (2.6 \times 10⁵%), and remarkable detectivity (D*) (3.1 \times 10¹³ Jones). Our work provides

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a new CVD method to grow high-quality SnS₂ nanosheets.

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Introduction

Tin disulfide (SnS₂) is very popular in electronic,¹⁻³ optoelectronic,⁴⁻⁷ and energy storage and conversion⁸⁻¹⁰ applications because of its many fascinating properties, such as layered structure, wide-bandgap ($\approx 2.2 \text{ eV}$), high absorption coefficient (10⁵ to 10⁶ cm⁻¹), large carrier mobility (230 cm² V⁻¹ s⁻¹),¹¹⁻¹³ earth-abundance, and environmentally friendly nature. In particular, SnS₂-based photodetectors showed an excellent responsivity, large on/off ratio, quick response, and fine stability,¹⁴ so they will have a bright future in the practical or commercial electronic and optoelectronic areas.

As we know, only the controllable growth of SnS₂ nanosheets can allow its integrated electronic/optoelectronic applications. Many preparation methods of SnS₂ nanosheets have been studied including exfoliation,¹⁵ the solvothermal method,¹⁶ atomic layer deposition (ALD),¹⁷ and chemical vapor deposition (CVD)¹⁸ up to now. However, in the exfoliation of bulk materials it is difficult to control the size and thickness of the nanosheets, which limits its large-scale device fabrication. The solvothermal method needs a long reaction time and a complicated postprocessing process. SnS₂ nanosheets prepared by ALD have the disadvantage of small size and different to transfer. CVD is expected to be the most promising method to grow various large-scale 2D materials. Peng *et al.*¹⁹ first grew an array of SnS₂ by CVD with a predefined location on the SiO₂/Si substrates. But the critical nucleation site required a nanofabrication process, which needed a long time and might introduce impurities. Meng *et al.*⁶ chose S and SnS₂ powders as the precursors to synthesize SnS₂ by CVD. Liu *et al.*²⁰ reported vertical SnS₂ synthesized on a fluorine-doped tin oxide (FTO) using CVD. However, the SnS₂ materials obtained by these results were not conducive to mass applications, because it was difficult to control the quality of products,^{6,19} for example, the size, the uniformity, the thickness. Some photodetectors based on SnS₂ showed low responsivities or slow response rates.²¹

In this work, large-area SnS_2 nanosheets were grown through a CVD method by using SnCl_2 on SiO_2/Si substrates as the precursors. The SnS_2 nanosheets-based photodetectors were fabricated to exhibit high responsivity (1400 A W⁻¹), fast response rate (a response time of 7 ms and a recovery time of 6 ms), perfect external quantum efficiency (EQE) ($2.6 \times 10^5\%$), and remarkable detectivity (D^*) (3.1×10^{13} Jones). Our work may provide a new CVD method to grow SnS_2 nanosheets with high-quality.

Materials and methods

SnS₂ nanosheets synthesis and characterization

The SnS₂ nanosheets were synthesized using SnCl₂ on SiO₂/Si substrates as the precursor and sulfurizing *via* a chemical vapor deposition (CVD) method. First, a stoichiometrical amount of tin chloride anhydrous (99.9%, Alfa) was melted thoroughly in ethanol to obtain a 0.2 M L⁻¹ SnCl₂ solution. Then the SnCl₂ solution was dispersed on a clean SiO₂/Si substrate by spincoating. The SiO₂/Si substrates with SnCl₂ were sulfurized by CVD after evaporated the ethanol. For CVD growth, a quartz

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boat contained several SiO₂/Si substrates with SnCl₂ was placed at the center of the furnace. Another guartz boat contained 0.1 g S powders (99.9%, Alfa) was placed on the upstream side of the furnace. The distance between the two quartz boats was about 10 cm. In the process of the SnS_2 growing, the furnace temperature was kept at 700 °C for 30 minutes, and then it was cooled to room temperature naturally. The flow rate of Ar gas was kept at 50 sccm all the time. The grown samples were characterized by an XRD (XRD-7000, Shimadzu), a field emission scanning electron microscope (JSM-7600F, JEOL, and Quanta650 FEG, FEI), an atomic force microscope (AFM, SPM9700, Shimadzu), and a transmission electron microscope (TEM, Tecnai G2 F30 S-TWIN, FEI). The Raman spectra were collected by an Argon ion laser Raman spectrometer (LabRAM HR800, Horiba Jobin Yvon) in the backscattering geometry with a 532 nm line. The Raman mapping was recorded by alpha300 R (WITec GmbH, Ulm, Germany) with a laser wavelength of 532 nm, and the scanning step interval was 300 nm.

Photodetectors fabrication and measurement

For the photodetectors based on SnS₂ fabrication, the ethanol dispersion solution of the as-grown SnS2 nanosheets was dropped on a SiO₂/Si substrate first. Then the SnS₂ nanosheetsbased photodetectors were fabricated using a standard electron beam lithography process (ELPHY Plus, Raith GmbH). The 10 nm Cr/50 nm Au electrodes were deposited by thermal evaporation (Nexdap, Angstrom Engineering). The photodetector was measured by a set of the photoelectric detection system, which contains a cryogenic probe station (CRX-6.5K, a semiconductor characterization Lakeshore), system (4200SCS, Keithley), a broadband laser-driven light source (LDLS, EQ-1500, Energetiq), and an oscilloscope (DSO-X 3052A, Keysight) with a 680 nm light pulse chopped at a frequency of 3 Hz.

Results and discussion

Fig. 1a showed the schematic of grown the SnS₂ nanosheets *via* a CVD method. The crystal structures of the SnS₂ nanosheets were identified by XRD, and the results were shown in Fig. 1b. The obtained X-ray diffractometer pattern depicted that the asgrown nanosheets were pure hexagonal SnS₂ crystal phase (JCPDS card no. 23-0677).²² Like MoS₂ crystals, each layer of SnS₂ consists of S–Sn–S, and the thickness is about 0.6 nm (in the inset of Fig. 1b). The top-view of the SEM image in Fig. 1c exposed the large amounts of SnS₂ nanosheets grew in the direction vertical to the SiO₂/Si substrate, and the average size was about 15 µm. SiO₂/Si substrates are 3D-bonded materials and have a large number of unsaturated dangling bonds on their surface. The migration barrier energies of SnS₂ adatoms on SiO₂/Si substrates are expected to be larger the diffusion SnS₂ species tend to grow out-of-plane on SiO₂/Si.²³

We then verified the as-grown SnS_2 nanosheets using Raman spectroscopy. There are always two different polytypes (2H and 4H) in the two-dimension SnS_2 crystals.²⁴ In 4H-SnS₂ crystals, the most intense Raman peak at 313.5 cm⁻¹ is from a mixture of

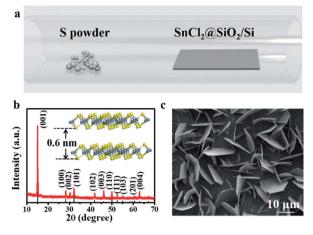


Fig. 1 (a) A schematic diagram of the CVD method. (b) XRD patterns of the as-grown nanosheets. Inset: crystal structure of the layered SnS_2 crystals. (c) A low-magnification SEM image of as-grown SnS_2 nanosheets.

 A_1 and E optical modes, and the peaks at 200 and 214 cm⁻¹ are identified to be the E-mode. In 2H-SnS2 crystals, the most intense peak at 315 cm⁻¹ is assigned to the A_{1g} mode, and the peak at 205 cm^{-1} is ascribed to the E_g mode. And if the thickness decreased down to the nanoscale, the Eg peak couldn't be detectable because of the reduction in the scattering centers for in-plane scattering in the ultrathin SnS2 nanosheets.²⁵ Compare with the Raman spectra of the as-grown SnS₂ nanosheets, it's easy to find the SnS₂ nanosheets belong to 2H-SnS₂ (Fig. 2a). Raman mapping (Fig. 2b) demonstrated the uniformity of the as-grown SnS₂ nanosheet. The thickness of the SnS₂ nanosheet was about 9 nm from the result of the atomic force microscope (AFM), as shown in Fig. 2c. According to a monolayer thickness of ≈ 0.6 nm, the nanosheet was about 15 layers. SnS₂ is a semiconductor with an indirect bandgap of \sim 2.2 eV, the bandgap remains indirect in few-layer and monolayer flakes, which has been demonstrated by theoretical and experimental

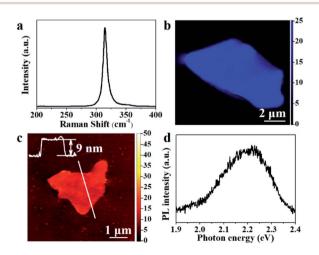


Fig. 2 (a) Raman spectrum of SnS_2 nanosheet. (b) Raman mapping data of SnS_2 nanosheet. (c) Typical AFM image of SnS_2 nanosheet. (d) PL spectra of SnS_2 nanosheet.

studies.²⁴ The PL spectra in Fig. 2d showed the bandgap of the as-grown SnS_2 nanosheet was ≈ 2.2 eV, which confirmed it had a high-quality crystalline structure.

To further evaluate the quality of as-grown SnS₂ nanosheets, we undertook a transmission electron microscope (TEM) to explore the lattice structure and the chemical composition information of the sample. Fig. 3a demonstrated a typical low-magnification TEM image of the SnS₂ nanosheet. The corresponding high-resolution TEM image in Fig. 3b showed the hexagonal lattice fringes, indicated the SnS₂ nanosheet had a perfect atomic structure with a lattice spacing of 0.316 nm, corresponding to the (01-10) and (10-10) planes. The selected area electron diffraction (SAED) and the sharp diffraction spots apparent in Fig. 3c also proved the highquality crystalline hexagonal structure of the SnS₂. Then, the elemental compositions of the SnS₂ nanosheet were acquired by the EDX mapping and the EDX spectrum. The EDX mapping in Fig. 3d and e, indicated the uniform distribution of Sn and S elements. EDX spectrum in Fig. 3f demonstrated the atomic ratio between S and Sn was approximately 2:1, which was consistent with the expected stoichiometry of SnS₂. The TEM results further proved that the as-grown SnS₂ nanosheets were high-quality crystalline SnS₂.

To investigate the optoelectronic properties of the SnS₂ nanosheet, photodetectors based on as-grown SnS2 nanosheets have been fabricated. Fig. 4a illustrated the spectral response curve of SnS₂ nanosheets from 300 nm to 800 nm. The photoresponse decreased at the wavelength of \approx 560 nm (bandgap of \approx 2.2 eV), which was consistent with the result of PL in Fig. 2d. *I–V* characteristics under 680 nm light illumination of 2.1 mW $\rm cm^{-2}$ and the dark, in air and vacuum of 2.0 \times 10^{-2} Pa were showed in Fig. 4b. The symmetric behavior of the I-V curves indicated an ohmic contact between the 10 nm Cr/50 nm Au electrodes and the SnS2 channel.26 Regardless of under 680 nm wavelengths or the dark, the currents in vacuum were higher than those in air. It could be explained by an air adsorption/ desorption mechanism. Because SnS₂ is an n-type semiconductor, its dominant carriers are the electrons. In the dark, the free electrons within the n-type SnS₂ channel will be trapped

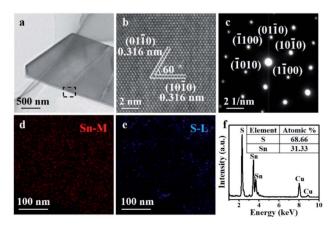


Fig. 3 (a) Low-magnification TEM image of the SnS₂ nanosheet. (b) High-resolution TEM image and (c) selected area electron diffraction (SAED) pattern image of the SnS₂ nanosheet. (d) and (e) Sn and S elemental mapping of the black rectangle region of the SnS₂ nanosheet in (a). (f) EDX spectrum of the SnS₂ nanosheet, inset: the ratio of Sn and S atoms.

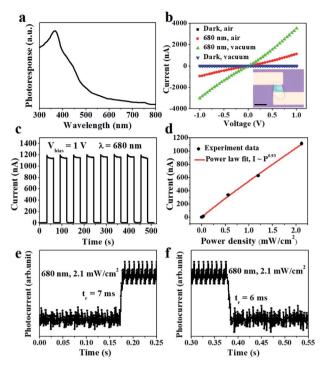


Fig. 4 (a) Spectral response curve of the SnS₂ nanosheet. (b) I-V characteristics under 680 nm wavelengths and the dark, in air and vacuum of 2.0×10^{-2} Pa. Inset: the optical image of the photodetector, the scale bar is 10 μ m. (c) Time-resolved photoresponse at a bias voltage of 1 V and an illumination power of 2.1 mW cm⁻² in air. (d) Photocurrent as a function of illumination intensity at $V_{\text{bias}} = 1$ V in air. (e) and (f) Response and recovery curves of the photodetector in air.

by the air adsorbates on the surface of SnS₂ nanosheets. The loss in the area formed on the surface will lead to the decrease of carrier density in the channel.14,27 However, if we turn on the incident light, the combination of the photogenerated holes (separated from electron-hole pairs) and the trapped electrons will release the air adsorbates on the SnS₂ surface. It is generally known that the air adsorbates such as oxygen could play an important role in the photoresponse process of other semiconductors especially for 2D semiconductors with a large specific surface area.²⁸ The surface trap states could achieve a longer lifetime of photogenerated carriers and thus guarantee a high R_{λ} and EQE.²⁹ As the results of the time-resolved photoresponse at a bias voltage of 1 V in air shown in Fig. 4c, the photodetector based on SnS₂ sustained a long-time stability response under switching on/off incident light illuminated on it periodically (Fig. 4c). The photo-responsivity (R_{λ}) of the photodetector was calculated to be 1.4×10^6 mA W⁻¹ through the equation: $R_{\lambda} = I_{\text{ph}}/PS$, where $I_{\text{ph}} = I_{\text{light}} - I_{\text{dark}}$ is the photoexcited current, P is the light power intensity (2.1 mW cm⁻²), and S is the effective area under incident light (Fig. 4b inset). Such high responsivity may come from the efficient absorption and optimized device fabrication.14 The external quantum efficiency (EQE) was also evaluated to be 2.6 \times 10⁵%, based on the equation: EQE = $hcR_{\lambda}/e\lambda$, where h is the Plank's constant, c is the light velocity, *e* is the elementary electronic charge, and λ is

Table 1	Comparison of the	key parameters of ou	r device to the reported 2D	material based photodetectors ^a
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Devices	Response range	Wavelength (nm)	$R_{\lambda} (\mathrm{mA} \mathrm{W}^{-1})$	EQE (%)	D* (Jones)	Rise time (ms)	Ref.
SnS_2	Vis	532	$1 imes 10^5$	_	_	44	24
SnS_2	UV-NIR	830	2.1×10^{-4}	_	_	460	21
SnS_2	Vis	473	$1 imes 10^5$	$3.3 imes10^4$	_	330	34
SnS_2	Vis	457	8.8	2.4	$2 imes 10^9$	$5 imes 10^3$	19
SnS_2	Vis	450	$2 imes 10^3$	—	_	42	6
SnS_2	UV-Vis	405	$1.5 imes10^3$	_	_	42	35
SnS_2	UV-NIR	532	0.65	0.15	$1.13 imes 10^8$	360	27
SnS_2	UV	350	$2.6 imes10^5$	$9.3 imes10^4$	$1.9 imes10^{10}$	20	14
SnS_2	Vis	400	1.19×10^3	_	$2.4 imes10^{11}$	<1	36
SnS_2	Vis	490	$1.85 imes10^3$	469	$4.9 imes10^9$	43.4	23
SnS_2	UV	390	_	150	_	_	37
SnS_2	UV	365	$1.1 imes 10^6$	$3.2 imes10^5$	$9.6 imes10^{11}$	40	38
SnS_2	Vis	405	$3.54 imes10^5$	$1.1 imes 10^5$	$2 imes 10^{10}$	0.4	11
SnS_2	Vis	532	2.08×10^3	_	$6 imes 10^6$	$3.4 imes10^3$	39
SnS_2	UV	350	8.6×10^5	$3.1 imes 10^5$	$1.1 imes 10^{10}$	700	40
BP	UV	365	$3.6 imes10^8$	1.6×10^6	$2.3 imes10^{13}$	$1 imes 10^3$	41
SnS	UV-NIR	660	$9.2 imes10^5$	$1.7 imes 10^5$	$1.09 imes10^9$	0.12	42
PtS_2	UV-NIR	830	$3 imes 10^2$	_	_	0.1	43
PtSe ₂	NIR	632	$4.5 imes10^3$	_	$7 imes 10^8$	1.1	44
PdSe ₂	IR	1064	$7.1 imes10^5$	_	$1.3 imes 10^9$	_	45
SnS ₂	Vis	680	1.4×10^6	$2.6 imes 10^5$	$3.1 imes 10^{13}$	7	This wo

the excitation light wavelength. The specific detectivity (D^*) is 3.1×10^{13} Jones according to the equation of $D^* = R_{\lambda} S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation of } D^* = R_{\lambda} S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation of } D^* = R_{\lambda} S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation of } D^* = R_{\lambda} S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation of } D^* = R_{\lambda} S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation of } D^* = R_{\lambda} S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times 10^{13} \text{ Jones according to the equation } S^{1/2} / (2e \times$ $I_{\rm dark}$)^{1/2}. The quality of the photodetector was further determined by fitting the relation of photocurrent and incident light power density with a power law, $I_{\rm ph} \approx P^{\theta}$. As shown in Fig. 4d, the exponent θ was fitted to be ≈ 0.93 , suggesting the SnS₂ had very few defects or traps to photo-induced electron/hole pairs in the test power density range.³⁰ From response and recovery curves in air (Fig. 4e and f), the rise time of the photodetector was \approx 7 ms, while the decay time was \approx 6 ms. The performance of our photodetector was more inspiring than the most reported SnS₂ based photodetectors shown in Table 1. Such superior responsivity and fast response rates were mainly due to the high-quality crystalline SnS2 structure, large specific surface area, and surface trap states. For example, (a) the high-quality crystalline structure without low density of defects confirmed by the PL spectra and TEM characterizations contributes to a rapid diffusion of charge carriers.³¹ (b) As well known, large specific surface area due to the ultrathin 2D structure could lead to higher sensitivity and prolong lifetime of photoexcited carriers because of a larger charge separation compared to their bulk counterparts.^{32,33} (c) Trap states at the surface may prolong the lifetime of photoexcited carriers. Finally, both high responsivity and fast response rates suggest that the surface trapping and recombination relative to the defects reach an equilibrium in the SnS₂ photodetector.²⁹

Conclusions

In summary, we have grown a large amount of high-quality SnS_2 nanosheets using $SnCl_2$ as the precursors *via* a CVD method. The as-grown SnS_2 nanosheets have been verified by XRD, SEM,

Raman/PL, AFM, TEM, and photodetectors, respectively. The SnS₂ nanosheet has an indirect bandgap ($\approx 2.2 \text{ eV}$), and its thickness is 9 nm (≈ 15 layers). The photodetector based on the SnS₂ nanosheets exhibits excellent performance, such as a high responsivity (1.4×10^6 mA W⁻¹), a fast response rates (a response time of 7 ms and a recovery time of 6 ms), and a perfect external quantum efficiency (EQE) (2.6×10^5 %). This work may provide a new method to grow the SnS₂ nanosheets, which could help the research and application of future 2D semiconductor materials.

Conflicts of interest

There are no conflicts to declare.

Acknowledgements

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